NOVEL ANTIMICROBIAL SURFACES BASED ON CuO-Cu₂O/TiO₂ NANOPARTICLES

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Antimicrobial touch surfaces have been implemented in healthcare settings to supplement current hygiene standards and aid in the problem against the growing threat of antimicrobial resistance. In this work, starting from Evonik (Degussa) P25 TiO₂ nanoparticles we prepared CuO-Cu₂O/TiO₂ nanoparticles by impregnation method [1] (with initial 2, 4, 8 wt.% copper concentration) for further investigation against gram-negative, gram-positive bacteria models and a fungal model.

Characterization of the surface coating was performed using XPS, UV-Vis, SEM and TEM techniques. XPS confirmed the presence of Cu in its two different oxide forms and allowed to monitor the ratio of these two oxides. No metallic copper was observable on the surface of prepared samples. We also investigated the influence of pH value (from 6.5 to 9.5) on impregnation process. The XPS analysis demonstrated, that higher pH value during impregnation caused higher Cu 2p / Ti 2p photoelectron peak ratio, i.e. higher amount of copper compounds on TiO₂ surface. It shows that higher pH value during impregnation caused more efficient copper deposition on the surface of TiO₂ nanoparticles. Also, evaluation of the photocatalytic activity of CuO-Cu₂O/TiO₂ suspensions was performed by the degradation rate of methylene blue under UV-light irradiation (UVA, 2.8 W/m²).

References

1. A. Ajmal et al. Journal of Environmental Chemical Engineering 4 (2016) 2138–2146

